

# HCS08MS

# Radiation Hardened **Quad 2-Input AND Gate**

August 1995

#### **Features**

- 3 Micron Radiation Hardened SOS CMOS
- Total Dose 200K RAD(Si)
- SEP Effective LET No Upsets: >100 MEV-cm<sup>2</sup>/mg
- Single Event Upset (SEU) Immunity < 2 x 10<sup>-9</sup> Errors/Bit-Day (Typ)
- Dose Rate Survivability: >1 x 10<sup>12</sup> Rads (Si)/s
- Dose Rate Upset >10<sup>10</sup> RAD(Si)/s 20ns Pulse
- Latch-Up Free Under Any Conditions
- Military Temperature Range: -55°C to +125°C
- Significant Power Reduction Compared to LSTTL ICs
- DC Operating Voltage Range: 4.5V to 5.5V
- Input Logic Levels
  - VIL = 30% of VCC Max
  - VIH = 70% of VCC Min
- Input Current Levels Ii  $\leq 5\mu A$  at VOL, VOH

## Description

The Intersil HCS08MS is a Radiation Hardened Quad 2-Input AND Gate. A high on both inputs force the output to a High state.

The HCS08MS utilizes advanced CMOS/SOS technology to achieve high-speed operation. This device is a member of radiation hardened, high-speed, CMOS/SOS Logic Family.

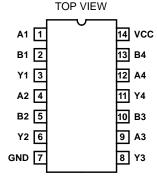
The HCS08MS is supplied in a 14 lead Ceramic Flatpack Package (K suffix) or a 14 lead SBDIP Package (D suffix).

# **Ordering Information**

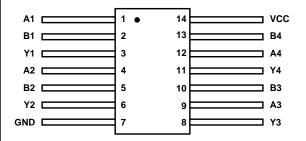
PART NUMBER	TEMPERATURE RANGE	SCREENING LEVEL	PACKAGE
NOWBER	KANGE	LEVEL	FACRAGE
HCS08DMSR	-55°C to +125°C	Intersil Class S Equivalent	14 Lead SBDIP
HCS08KMSR	-55°C to +125°C	Intersil Class S Equivalent	14 Lead Ceramic Flatpack
HCS08D/ Sample	+25°C	Sample	14 Lead SBDIP
HCS08K/ Sample	+25°C	Sample	14 Lead Ceramic Flatpack
HCS08HMSR	+25°C	Die	Die

#### **Pinouts**

14 LEAD CERAMIC DUAL-IN-LINE **METAL SEAL PACKAGE (SBDIP)** MIL-STD-1835 CDIP2-T14



14 LEAD CERAMIC METAL SEAL FLATPACK PACKAGE (FLATPACK) MIL-STD-1835 CDFP3-F14 TOP VIEW



#### TRUTH TABLE

INP	OUTPUTS	
An	Bn	Yn
L	L	L
L	Н	L
Н	L	L
Н	Н	Н

NOTE: L = Logic Level Low, H = Logic level High

## Functional Diagram

(1, 4, 9, 12) (3, 6, 8, 11) (2, 5, 10, 13)Bn

### **Absolute Maximum Ratings**

#### 

Junction Temperature (TJ) +175°C ESD Classification Class 1

## Reliability Information

Thermal Resistance SBDIP Package Ceramic Flatpack Package	θ <sub>JA</sub> 74°C/W 116°C/W	θ <sub>JC</sub> 24°C/W 30°C/W
		30 O/VV
Maximum Package Power Dissipation at +12	5°C	
SBDIP Package		0.66W
Ceramic Flatpack Package		0.43W
If device power exceeds package dissipation	capability, p	rovide heat
sinking or derate linearly at the following rate		
SBDIP Package	1	3.5mW/°C
Ceramic Flatpack Package		

CAUTION: As with all semiconductors, stress listed under "Absolute Maximum Ratings" may be applied to devices (one at a time) without resulting in permanent damage. This is a stress rating only. Exposure to absolute maximum rating conditions for extended periods may affect device reliability. The conditions listed under "Electrical Performance Characteristics" are the only conditions recommended for satisfactory device operation.

#### **Operating Conditions**

Supply Voltage	Input Low Voltage (VIL)
Input Rise and Fall Times at 4.5V VCC (TR, TF) 100ns/V Max	Input High Voltage (VIH) 70% of VCC to VCC
Operating Temperature Range (T <sub>A</sub> )55°C to +125°C	

#### TABLE 1. DC ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTE 1)	GROUP A SUB-		LIM	IITS	
PARAMETERS	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	10	μА
		VIIV = VGC OI GIVD	2, 3	+125°C, -55°C	-	200	μА
Output Current (Sink)	IOL	VCC = 4.5V, VIH = 4.5V, VOUT = 0.4V, VIL = 0V	1	+25°C	4.8	-	mA
(Ollik)		VOOT = 0.4V, VIL = 0V	2, 3	+125°C, -55°C	4.0	-	mA
Output Current (Source)	IOH	VCC = 4.5V, VIH = 4.5V, VOUT = VCC -0.4V,	1	+25°C	-4.8	-	mA
(Gource)		VIL = 0V	2, 3	+125°C, -55°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V, VIH = 3.15V, IOL = 50μA, VIL = 1.35V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	٧
		VCC = 5.5V, VIH = 3.85V, IOL = 50μA, VIL = 1.65V	1, 2, 3	+25°C, +125°C, -55°C	-	0.1	V
Output Voltage High	VOH	VCC = 4.5V, VIH = 3.15V, IOH = -50μA, VIL = 1.35V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
		VCC = 5.5V, VIH = 3.85V, IOH = -50μA, VIL = 1.65V	1, 2, 3	+25°C, +125°C, -55°C	VCC -0.1	-	V
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	1	+25°C	-	±0.5	μΑ
Current		GND	2, 3	+125°C, -55°C	-	±5.0	μА
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 0.70(VCC), VIL = 0.30(VCC) (Note 2)	7, 8A, 8B	+25°C, +125°C, -55°C	-	-	-

#### NOTES:

- 1. All voltages reference to device GND.
- 2. For functional tests, VO ≥ 4.0V is recognized as a logic "1", and VO ≤ 0.5V is recognized as a logic "0".

TABLE 2. AC ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTES 1, 2)	GROUP A SUB-		LIM	IITS	
PARAMETER	SYMBOL	CONDITIONS	GROUPS	TEMPERATURE	MIN	MAX	UNITS
Input to Yn	TPHL	VCC = 4.5V	9	+25°C	2	18	ns
			10, 11	+125°C, -55°C	2	20	ns
Input to Yn	TPLH	VCC = 4.5V	9	+25°C	2	18	ns
			10, 11	+125°C, -55°C	2	20	ns

#### NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL =  $500\Omega$ , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = VCC.

TABLE 3. ELECTRICAL PERFORMANCE CHARACTERISTICS

					LIMITS		
PARAMETER	SYMBOL	CONDITIONS	NOTES	TEMPERATURE	MIN	MAX	UNITS
Capacitance Power Dissipation	CPD	VCC = 5.0V, f = 1MHz	1	+25°C	-	18	pF
Dissipation			1	+125°C, -55°C	-	25	pF
Input Capacitance	CIN	VCC = 5.0V, f = 1MHz	1	+25°C	-	10	pF
			1	+125°C	-	10	pF
Output Transition Time	TTHL TTLH	VCC = 4.5V	1	+25°C	-	15	ns
Time	'''		1	+125°C	-	22	ns

## NOTE:

TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS

		(NOTES 1 2)		200K RA	D LIMITS	
PARAMETERS	SYMBOL	(NOTES 1, 2) CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Quiescent Current	ICC	VCC = 5.5V, VIN = VCC or GND	+25°C	-	0.2	mA
Output Current (Sink)	IOL	VCC = 4.5V, VIN = VCC or GND, VOUT = 0.4V	+25°C	4.0	-	mA
Output Current (Source)	IOH	VCC = 4.5V, VIN = VCC or GND, VOUT = VCC -0.4V	+25°C	-4.0	-	mA
Output Voltage Low	VOL	VCC = 4.5V and 5.5V, VIH = 0.70(VCC), VIL = 0.30(VCC) at 200K RAD, IOL = $50\mu A$	+25°C	-	0.1	V
Output Voltage High	VOH	VCC = 4.5V and 5.5V, VIH = 0.70(VCC), VIL = 0.30(VCC) at 200K RAD, IOH = -50μA	+25°C	VCC -0.1	-	V
Input Leakage Current	IIN	VCC = 5.5V, VIN = VCC or GND	+25°C	-	±5	μΑ

<sup>1.</sup> The parameters listed in Table 3 are controlled via design or process parameters. Min and Max Limits are guaranteed but not directly tested. These parameters are characterized upon initial design release and upon design changes which affect these characteristics.

TABLE 4. DC POST RADIATION ELECTRICAL PERFORMANCE CHARACTERISTICS (Continued)

		(NOTES 1, 2)		200K RA	D LIMITS	
PARAMETERS	SYMBOL	CONDITIONS	TEMPERATURE	MIN	MAX	UNITS
Noise Immunity Functional Test	FN	VCC = 4.5V, VIH = 0.70(VCC), VIL = 0.30(VCC) at 200K RAD, (Note 3)	+25°C	-	-	-
Input to Yn	TPHL	VCC = 4.5V	+25°C	2	18	ns
	TPLH	VCC = 4.5V	+25°C	2	20	ns

#### NOTES:

- 1. All voltages referenced to device GND.
- 2. AC measurements assume RL =  $500\Omega$ , CL = 50pF, Input TR = TF = 3ns, VIL = GND, VIH = VCC.
- 3. For functional tests,  $VO \ge 4.0V$  is recognized as a logic "1", and  $VO \le 0.5V$  is recognized as a logic "0".

TABLE 5. BURN-IN AND OPERATING LIFE TEST, DELTA PARAMETERS (+25°C)

PARAMETER	GROUP B SUBGROUP	DELTA LIMIT
ICC	5	3µА
IOL/IOH	5	-15% of 0 Hour

#### **TABLE 6. APPLICABLE SUBGROUPS**

		GROUP A SUBGROUPS		
COMFORMANCE GROUP	MIL-STD-883 METHOD	TESTED	RECORDED	
Initial Test	100% 5004	1, 7, 9	1 (Note 2)	
Interim Test	100% 5004	1, 7, 9, Δ	1, Δ (Note 2)	
PDA	100% 5004	1, 7, Δ		
Final Test	100% 5004	2, 3, 8A, 8B, 10, 11		
Group A (Note 1)	Sample 5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11		
Subgroup B5	Sample 5005	1, 2, 3, 7, 8A, 8B, 9, 10, 11, Δ	1, 2, 3, Δ (Note 2)	
Subgroup B6	Sample 5005	1, 7, 9		
Group D	Sample 5005	1, 7, 9		

#### NOTES:

- 1. Alternate Group A testing in accordance with MIL-STD-883 Method 5005 may be exercised.
- 2. Table 5 parameters only.

**TABLE 7. TOTAL DOSE IRRADIATION** 

CONFORMANCE		TEST		READ AND	RECORD
GROUPS	METHOD	PRE RAD	POST RAD	PRE RAD	POST RAD
Group E Subgroup 2	5005	1, 7, 9	Table 4	1, 9	Table 4 (Note 1)

#### NOTE:

1. Except FN test which will be performed 100% Go/No-Go.

TABLE 8. STATIC AND DYNAMIC BURN-IN TEST CONNECTIONS

				OSCILLATOR			
OPEN	GROUND	1/2 VCC = 3V $\pm$ 0.5V	$\text{VCC} = 6\text{V} \pm 0.5\text{V}$	50kHz	25kHz		
STATIC BURN-IN I TEST CONDITIONS (Note 1)							
3, 6, 8, 11	1, 2, 4, 5, 7, 9, 10, 12, 13	-	14	-	-		
STATIC BURN-IN II TEST CONNECTIONS (Note 1)							
3, 6, 8, 11	7	-	1, 2, 4, 5, 9, 10, 12, 13, 14	-	-		
DYNAMIC BURN-IN I TEST CONNECTIONS (Note 2)							
-	7	3, 6, 8, 11	14	1, 2, 4, 5, 9, 10, 12, 13	-		

#### NOTES:

- 1. Each pin except VCC and GND will have a resistor of 10K $\Omega$  ± 5% for static burn-in.
- 2. Each pin except VCC and GND will have a resistor of 1K $\!\Omega\pm5\%$  for dynamic burn-in.

**TABLE 9. IRRADIATION TEST CONNECTIONS** 

OPEN	GROUND	$\text{VCC} = 5\text{V} \pm 0.5\text{V}$
3, 6, 8, 11	7	1, 2, 4, 5, 9, 10, 12, 13, 14

NOTE: Each pin except VCC and GND will have a resistor of 47K $\Omega$   $\pm$  5% for irradiation testing. Group E, Subgroup 2, sample size is 4 dice/wafer 0 failures.

#### HCS08MS

## Intersil Space Level Product Flow - 'MS'

Wafer Lot Acceptance (All Lots) Method 5007 (Includes SEM)

GAMMA Radiation Verification (Each Wafer) Method 1019, 4 Samples/Wafer, 0 Rejects

100% Nondestructive Bond Pull, Method 2023

Sample - Wire Bond Pull Monitor, Method 2011

Sample - Die Shear Monitor, Method 2019 or 2027

100% Internal Visual Inspection, Method 2010, Condition A

100% Temperature Cycle, Method 1010, Condition C, 10 Cycles

100% Constant Acceleration, Method 2001, Condition per Method 5004

100% PIND, Method 2020, Condition A

100% External Visual

100% Serialization

100% Initial Electrical Test (T0)

100% Static Burn-In 1, Condition A or B, 24 hrs. min., +125°C min., Method 1015

100% Interim Electrical Test 1 (T1)

100% Delta Calculation (T0-T1)

100% Static Burn-In 2, Condition A or B, 24 hrs. min.,  $+125^{\circ}$ C min., Method 1015

100% Interim Electrical Test 2 (T2)

100% Delta Calculation (T0-T2)

100% PDA 1, Method 5004 (Notes 1 and 2)

100% Dynamic Burn-In, Condition D, 240 hrs., +125°C or Equivalent, Method 1015

100% Interim Electrical Test 3 (T3)

100% Delta Calculation (T0-T3)

100% PDA 2, Method 5004 (Note 2)

100% Final Electrical Test

100% Fine/Gross Leak, Method 1014

100% Radiographic, Method 2012 (Note 3)

100% External Visual, Method 2009

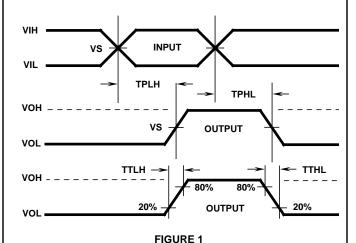
Sample - Group A, Method 5005 (Note 4)

100% Data Package Generation (Note 5)

#### NOTES:

- 1. Failures from Interim electrical test 1 and 2 are combined for determining PDA 1.
- 2. Failures from subgroup 1, 7, 9 and deltas are used for calculating PDA. The maximum allowable PDA = 5% with no more than 3% of the failures from subgroup 7.
- 3. Radiographic (X-Ray) inspection may be performed at any point after serialization as allowed by Method 5004.
- 4. Alternate Group A testing may be performed as allowed by MIL-STD-883, Method 5005.
- 5. Data Package Contents:
  - Cover Sheet (Intersil Name and/or Logo, P.O. Number, Customer Part Number, Lot Date Code, Intersil Part Number, Lot Number, Quantity).
  - Wafer Lot Acceptance Report (Method 5007). Includes reproductions of SEM photos with percent of step coverage.
  - GAMMA Radiation Report. Contains Cover page, disposition, Rad Dose, Lot Number, Test Package used, Specification Numbers, Test equipment, etc. Radiation Read and Record data on file at Intersil.
  - · X-Ray report and film. Includes penetrometer measurements.
  - Screening, Electrical, and Group A attributes (Screening attributes begin after package seal).
  - Lot Serial Number Sheet (Good units serial number and lot number).
  - Variables Data (All Delta operations). Data is identified by serial number. Data header includes lot number and date of test.
  - The Certificate of Conformance is a part of the shipping invoice and is not part of the Data Book. The Certificate of Conformance is signed by an authorized Quality Representative.

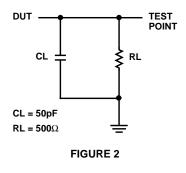
# **AC Timing Diagrams**



#### **AC VOLTAGE LEVELS**

PARAMETER	HCS	UNITS
VCC	4.50	V
VIH	4.50	V
VS	2.25	V
VIL	0	V
VSS	0	V

## **AC Load Circuit**



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## HCS08MS

## Die Characteristics

#### **DIE DIMENSIONS:**

87 x 88 mils 2.20 x 2.24mm

## **METALLIZATION:**

Type: AlSi

Metal Thickness: 11kÅ ± 1kÅ

## **GLASSIVATION:**

Type: SiO<sub>2</sub>

Thickness: 13kÅ ± 2.6kÅ

## **WORST CASE CURRENT DENSITY:**

 $< 2.0 \times 10^5 \text{A/cm}^2$ 

## **BOND PAD SIZE:**

 $100\mu m\ x\ 100\mu m$  4 mils x 4 mils

# Metallization Mask Layout

## HCS08MS

